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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/829,060	04/20/2004	Su-Tsai Lu	04146-UPL	7493
33804	7590 08/23/2006		EXAMINER	
LIN & ASSOCIATES INTELLECTUAL PROPERTY			NGUYEN, HOA CAO	
P.O. BOX 2 SARATOG	339 A, CA 95070-0339		ART UNIT PAPER NUMBER	
	, -		2841	
			DATE MAILED: 08/23/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)	C		
	10/829,060	LU ET AL.			
Office Action Summary	Examiner	Art Unit			
	Hoa C. Nguyen	2841			
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence ac	Idress		
A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING D  - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period  - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION  (36(a). In no event, however, may a reply be tirged and will expire SIX (6) MONTHS from the cause the application to become ABANDONE	N. nely filed the mailing date of this c (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 3.					
2a) This action is <b>FINAL</b> . 2b) ☑ This	s action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
4) ☐ Claim(s) 1-29 is/are pending in the application 4a) Of the above claim(s) 11-13 and 18-29 is/a 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-10 and 14-17 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or	are withdrawn from consideration.				
Application Papers					
9)⊠ The specification is objected to by the Examine	er.				
10)⊠ The drawing(s) filed on <u>20 April 2004</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.					
Applicant may not request that any objection to the	• • • • • • • • • • • • • • • • • • • •				
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex	•	•			
Priority under 35 U.S.C. § 119					
a) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a list	ts have been received. ts have been received in Applicat brity documents have been receiv u (PCT Rule 17.2(a)).	ion No ed in this National	Stage		
Attachment(s)  1)	4) 🔲 Interview Summary	/ (PTO-413)			
<ul> <li>Notice of References Cited (PTO-652)</li> <li>Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)</li> <li>Paper No(s)/Mail Date 1Pq.</li> </ul>	Paper No(s)/Mail D	ate	O-152)		

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### **DETAILED ACTION**

1. Claims 11-13 and 18-29 withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention group, there being no allowable generic or linking claim. Election was made **without** traverse in the reply filed on 6/24/06. Claims 1-10 and 14-17 are treated on the merits in this Office Action.

## Specification

- 2. The disclosure is objected to because of the following informalities:
  - (a) Specification, page 6, line 20: The "silicone" must be changed to "silicon".

    Appropriate correction is required.

### Claim Objections

- 3. Claims 1-10 and 14-17 are objected to because of the following informalities:
  - (a) Claim 1: The "plural" in lines 5, 6, 9, 11, and in claim 17, line 2 must be changed to "plurality" for the consistency with the "a plurality of ..".
  - (b) Claim 17: The "plural" in line 2 must be changed to "plurality" for the consistency with the "a plurality of .." in claim 1.
  - (c) Claims 6 and 7: The "silicone" must be changed to "silicon".
  - (d) Claims 2-10 and 14-17 are dependent claims of claim 1.

Appropriate correction is required.

# Claim Rejections - 35 USC § 112

4. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

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5. Claims 1-10 and 14-17 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Regarding claims 1, 4 and 5, the limitation "a buffer layer being coated on said protection layer and said plural of metal pad" fails to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

The buffer layer is indeed being coated on the protection layer 105 and on the first adhesive metal layer 110. The buffer layer is not coated on the metal pad 103, as disclosed in the drawings.

For continuing examination, the examiner only considers the buffer layer is being coated on the protection layer 105 and on the first adhesive metal layer 110.

<u>Examiner remarks</u>: The examiner suggests the "a buffer layer being coated on said protection layer and said plural of metal pad" be changed to "a buffer layer being coated on said protection layer and said <u>first adhesive metal layer</u>".

Regarding claim 1, the limitation "a first metal layer covering said buffer layer" fails to particularly point out and distinctly claims the subject matter which applicant regards as the invention.

As disclosed in the specification and in the drawings, the first metal layer 109 is indeed formed on a surface of the buffer layer 107/107a/107b but independently distributed over the areas that are parallel and adjacent to the metal pads.

The limitation creates an impression that the first metal layer 109 continuously distributed over a surface of the buffer layer. This limitation creates a short circuit when

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the electrodes 113a and 113b. The short circuit is not occur if and only if the metal layer 109 is discrete over the areas parallel and adjacent to the metal pads.

For continuing examination, the examiner considers the metal layer 109 is discrete.

<u>Examiner remarks</u>: The examiner suggests the "a first metal layer covering said buffer layer" be changed to:

"a first metal layer covering on said buffer layer over a surface area opposite to said first adhesive metal layer and said protection layer, wherein said first metal layer is independently distributed over said buffer surface areas that are parallel and adjacent to the first adhesive metal layer".

Claims 2-10 and 14-17 are dependent claims of claim 1.

### Allowable Subject Matter

6. Claims 1-10 and 14-17 would be allowable if rewritten or amended to overcome the rejection(s) under 35 U.S.C. 112, 2nd paragraph, set forth in this Office action.

### Reasons for Allowance

7. The following is an examiner's statement of reasons for allowance: The prior arts fail to teach, disclose, suggest, either alone or in combination, at least on claim 1, a combination of a buffer layer formed in between a metal adhesive layer and a metal layer and a bonding layer formed on another substrate/layer/board/card/chip, wherein the bonding layer and electrodes (formed on the same surface as the bonding layer) are independently distributed.

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance.

#### Citation of Relevant Art

8. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure:

Leung (US 6872984) discloses a method of sealing a hermetic lid to a semiconductor die at an angle.

Chen (US 6618269) discloses a discrete circuit component and process of fabrication.

Chiu et al. (US 6586322) disclose a method of making a bump on a substrate using multiple photoresist layers.

Kudoh et al. US 6373714) disclose a surface mounting part.

Tanaka (US 5889326) discloses a structure for bonding semiconductor device to substrate.

Tatoh et al. (US 20030005582) disclose a circuit board, method for manufacturing same, and high-output module.

Hirashima et al. (US 6309737) disclose a circuit substrate.

Hogerton et al. (US 5714252) disclose a deformable substrate assembly for adhesively bonded electronic device.

Ishikawa et al. (US 7069645) disclose a method for producing a circuit board.

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Shimizu (US 6740823) discloses a solder bonding method, and electronic device and process for fabricating the same.

Lauffer et al. (US 6739027) disclose a method for producing printed circuit board with embedded decoupling capacitance.

Perry et al. (US 6858111) disclose a conductive polymer interconnection configurations.

Liu et al. (US 6744142) disclose a flip chip interconnection structure and process of making the same.

Kang et al. (US 6337522) disclose a structure employing electrically conductive adhesives.

Perry H. et al. (US 6333104) disclose a conductive polymer interconnection configurations.

#### Conclusion

9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hoa C. Nguyen whose telephone number is 571-272-8293. The examiner can normally be reached on M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Kammie Cuneo can be reached on 571-272-1957. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR.

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Hoa C. Nguyen 8/16/06

SUPERVISORY PATENT EXAMINER
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